



AUTOMATED CHEMICAL SOLUTIONS

Chemicals and Controllers for PWB Fabrication

Product Overview

AUTOstrip RS-5532

Photoresist Stripper

Product Description

AUTOstrip RS-5532 is a photoresist stripper concentrate formulated specifically for use with today's multipurpose and plating photoresists. AUTOstrip RS-5532 is formulated to break the resist into very small piece sizes to aid in removal from fine and/or overplated features without the use of glycol ethers. AUTOstrip RS-5532 strips quickly at very low concentrations and leaves the copper surface clean and free of oxidation. AUTOstrip RS-5532 is designed to completely remove the tenacious adhesion promoters used in many of today's photoresists.

Physical Properties

Specific gravity:	1.0
pH:	> 13
Appearance:	clear, light amber liquid
Flash point:	> 200 °F

Operating Parameters

Concentration:	5 - 12% v/v
Temperature:	120 – 160 °F

Safety

CAUTION! RS-5532 concentrates and working solutions contain strong alkaline ingredients. Avoid contact with eyes, skin and clothing. Wear chemical handler's gloves, goggles and protective clothing when handling. Read and understand Material Safety Data Sheet before using this product.

Notice

The information and recommendations of Automated Chemical Solutions, Inc., and its representatives, regarding this product are, to the best of our knowledge, true and accurate. We make no guarantee of results because the conditions of actual use are beyond our control. We assume no liability for damages or penalties resulting from the use of this product or following our recommendations. Our recommendations and suggestions for use of this product are not intended to grant license to operate under or infringe any patent.